

# eGaN® FET Small Signal RF Performance



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Even though the eGaN FET was designed and optimized as a power-switching device, it also exhibits good RF characteristics. The smallest 200 V eGaN FET, EPC2012 [3], was selected for RF evaluation and should be viewed as a starting point from which the RF characteristics of future eGaN FET part numbers can be optimized for even better RF performance at higher frequencies.

RF FETs differ from power switching FETs in that they designed to work best in the linear region of operation to maximize power gain and minimize distortion, whereas power switching devices are optimized for lowest  $R_{DS(on)}$  and gate charge [1,2,3,17,18,19,20]. Another significant difference between power switching and RF FETs is the power dissipation capability of RF devices is significantly higher than that of power switching devices for equivalent terminal characteristics to accommodate the higher power losses in the linear region.

This paper focuses on RF characterization in the frequency range from 200 MHz through 2.5 GHz.

## eGaN FET RF CHARACTERIZATION

Prior to being able to compare various RF FETs with each other, they need to be properly characterized which can be accomplished by measuring the S-parameters of the FET while regarding it as a 2-port network under controlled bias conditions.

A test fixture (EPC9903) was designed for the EPC2012 to connect the RF signals to the FET and to provide the necessary S-parameter measurement reference planes from which the dataset would be valid. The test fixture design used a 30 mil thick Rogers 4350 substrate [21], chosen for its low losses at higher frequencies. This allowed the design to be suitable for frequencies as high as 12 GHz. Figure 1 shows the reference plane design and highlights the outline of the EPC2012 device. The transmission lines to the device Gate and Drain were designed as microstrip transmission lines with 50 Ω characteristic impedance.

The test fixture was also equipped with a negative temperature co-efficient thermistor (NTC) placed in close proximity to the source pad of the eGaN FET to provide an indication of the temperature of the copper in that area without affecting the RF performance. Figure 2 shows a photograph of the EPC9903 test fixture, with the right side image showing the top mounted heat-sink. The EPC FET has a lower thermal resistance [3] from junction to the top side of the device, compared to the bottom side (soldered), and hence mounting the heat-sink to the back side of the device has a high impact on the power dissipation capability of the device.

Due to thermal limitations of the test fixture and the EPC2012 device, testing of the eGaN FET was limited to pulsed based tests. The device was pulsed with a low duty cycle bias with the

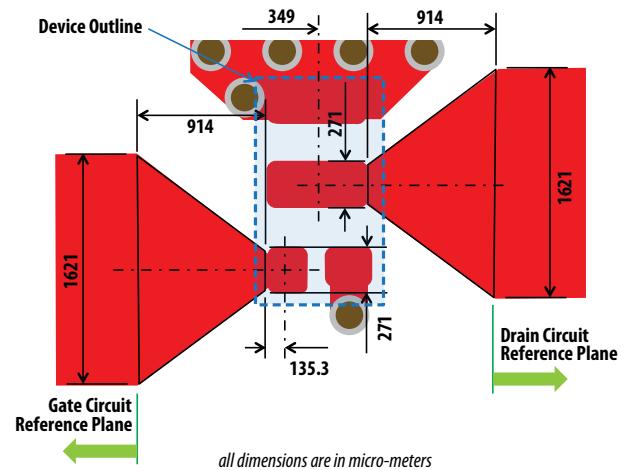


Figure 1: Reference plane design for the EPC2012 eGaN FET using 30mil thick Rogers 4350 substrate

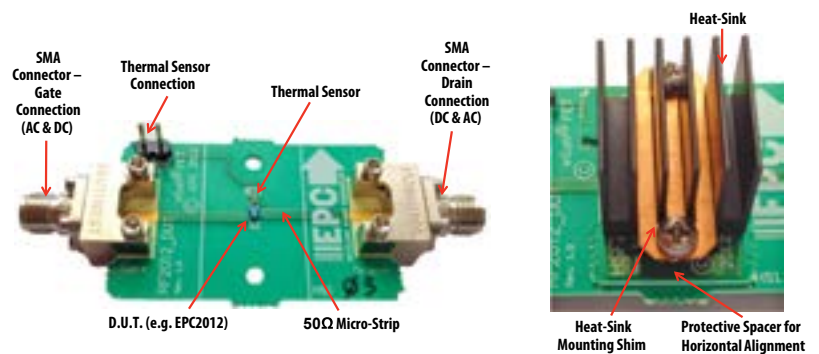


Figure 2: Photograph of the EPC9903 small signal RF test fixture for the EPC2012 eGaN FET (with heatsink mounted shown in right image)

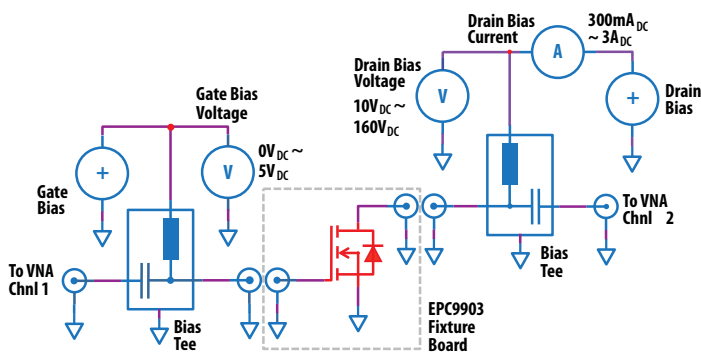


Figure 3: Basic test fixture schematic and RF small signal test setup

average power dissipation kept below 0.7 W without the heat-sink, and 5 W with the heat-sink and forced air cooling. The heat-sink used was 15 mm x 15 mm x 14.5 mm high made by Advanced Thermal Solutions [14] with thermal interface material from Wakefield [7].

**SMALL SIGNAL RF MEASUREMENT SETUP**

The basic setup using the EPC9903 test fixture is shown in Figure 3. Both the bias and RF signal are provided to the board using SMA connectors [23]. A bias Tee [4], was used for the separate connection of gate/ drain bias and the RF signal.

Prior to using the test fixture (EPC9903) for the S-parameter measurement of the EPC2012 device, it was calibrated using the Thru-Reflect-Line (TRL) method [10]. The process followed is well documented and similar to that described in [11].

**SMALL SIGNAL MEASUREMENT FOR HIGHEST MAXIMUM GAIN BIAS SETTING**

With the small signal S-parameter setup complete, the next step was to measure the EPC2012 device at various bias conditions to determine the highest maximum gain bias point. This will then be used to design a class A power amplifier to evaluate the large signal RF power performance of the EPC2012.

Initial testing to determine the useful gain frequency range of the device swept the frequency from 30 MHz through 12 GHz under continuous wave (CW) conditions at a low drain bias voltage of 10 V and 300 mA. Subsequent testing was limited to the 200 MHz through 2.5 GHz frequency range. Initial testing also investigated the influence of the heat-sink on the RF performance of the test fixture and the device. It was found that the impact of the heat-sink only became detectable above 2.5 GHz and caused a resonance around 6.5 GHz which is well above the working frequency of the device.

Various drain bias conditions were then applied to the FET terminals from 10 V through 70 V and from 10's of mA though 6 A as small signal S-Parameter measurements were taken. Under these conditions the bias power dissipation in the FET became significant and therefore the device was pulsed for short durations while measurements were taken. The pulse width was set to approximately 20 μs with a repetition frequency of 50 Hz.

For this discussion the gate-source circuit will be designated as port-1 and the drain-source circuit as port-2. Figure 4 shows a graph of maximum gain at 500 MHz as a function of drain bias power. The graph clearly shows that once the drain bias power exceeds 20 W there is very little increase in maximum gain with further increase in drain bias power. It also shows a nearly constant gain with drain voltage beyond 15 V bias. The graph shows the useful drain bias power range for a class A amplifier highlighted by the region of interest and will be the design point for such an amplifier. It is important to note that, for an amplifier design the drain bias must have sufficient voltage to allow the drain to swing with maximum amplitude. Too high of a voltage will lead to unnecessary drain bias power, and too low of a voltage will reduce the 1 dB compression point and induce clipping.

Figure 5 shows a graph of maximum gain as a function of frequency for various drain bias power conditions ranging from 10 W through 179 W. It should be noted that low drain bias power reduces the gain more above 600 MHz and, at

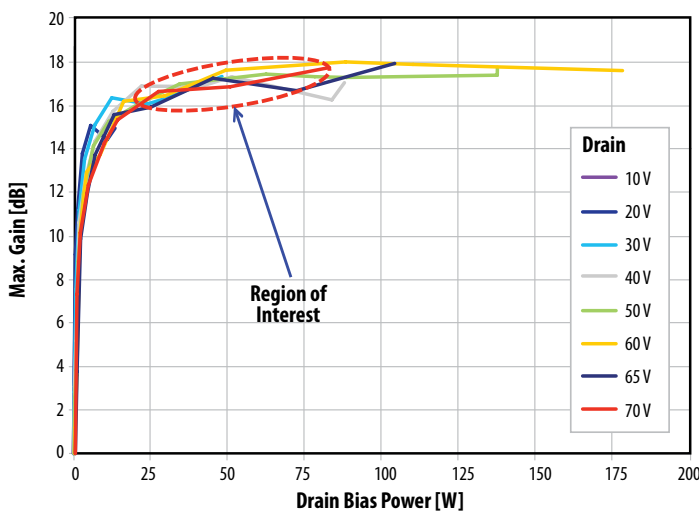


Figure 4: Graph of small signal Max. Gain as function of various Drain bias powers at 500 MHz as measured for the EPC2012 eGaN FET

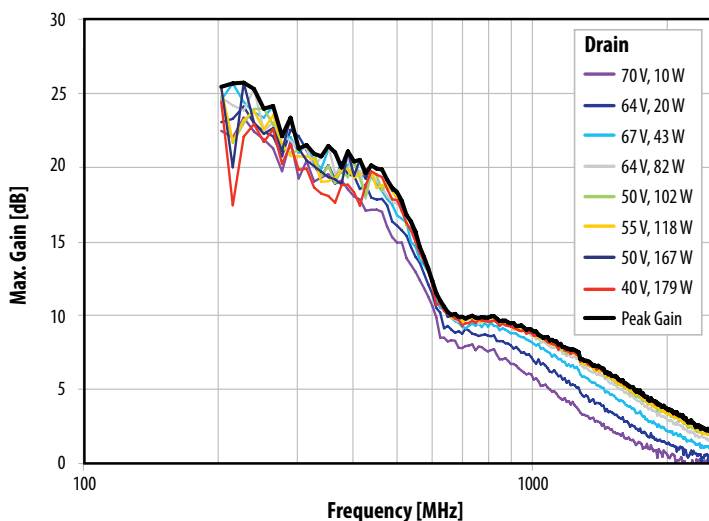


Figure 5: Maximum Gain at various Drain Bias conditions

very high drain bias power, gain reduces below 400 MHz.

Three optimal drain bias points have been identified from the data that can be used to evaluate the performance of the EPC2012 device as a class A amplifier operating at 500 MHz. The drain bias voltage is around 65 V with drain power of 20 W, 40 W and 80 W respectively. The 500 MHz point was chosen as it yielded the highest gain frequency product for various devices tested. The various drain bias power points will further be used to determine the impact on the 1 dB compression point and drain efficiency.

**PARAMETERS FOR AN RF POWER AMPLIFIER DESIGN**

Suitable drain bias points and frequency have been selected for the EPC2012 device based on maximum gain and frequency. The S-parameters at these bias points and frequency that can be used in the design of an RF power amplifier will be analyzed next.

Figure 6 shows the Smith Chart plot for the gate (S11) and drain (S22) reflection coefficients from 200 MHz through 2.5 GHz with a drain bias of 64 V and 1.275 A. A change in drain current has negligible impact on the input and output impedances. However, a reduction in drain voltage to below 15 V will have a significant impact on the input and output impedance as the  $C_{oss}$  of the eGaN FET increases dramatically. This will also reduce the available gain as more output current is shunted internally in the device reducing the output voltage swing. This issue must be accounted for when designing a large signal amplifier and falls outside the scope of this discussion.

The Smith chart plot shows that the EPC2012 device has low impedance for both the gate and drain circuits in the region from 200 MHz through 2.5 GHz, and of particular interest at 500 MHz where both are capacitive.

Based on measurement data, at 500 MHz the gate-source impedance is  $5.44 - j3.69 \Omega$  and the drain-source impedance is  $3.13 - j3.08 \Omega$  and can be used to determine matching networks for the device. The impact of bias networks, and whether an amplifier must be unconditionally stable, must also be considered prior to matching network design.

A stability analysis, based on the Rollett Stability [22] condition where  $|\Delta| < 1$  and  $K > 1$  [1, 15], indicates that the EPC2012 device is close to, but not unconditionally stable at 500 MHz where  $|\Delta| = 0.722$  and  $K = 0.673$ . The stability circle plot at 500 MHz, 64 V and 1.275 A drain bias is shown in Figure 7 with the unstable regions highlighted. A change in drain bias current, as in the case of input and output impedances, has a negligible impact on the location and size of the stability circles. The Smith Chart shows that the unstable regions are small. To ensure unconditional stability for an amplifier, a small series resistance in the RF gate circuit will suffice to shift the impedance to the right on the Smith Chart thereby ensuring unconditional stability. This solution is not practical for the output as the power may be high and the resistor will dissipate a large amount of RF power, thereby reducing the effective gain of the amplifier. A low Q factor matching network consisting of 2 L-section networks was chosen for the output to allow for exploration of broadband amplifier performance characteristics. This also tends to reduce losses in the matching network since smaller inductors may be used with corresponding lower resistive loss and is particularly useful for large transformations such as  $2 \Omega$  to  $50 \Omega$ .

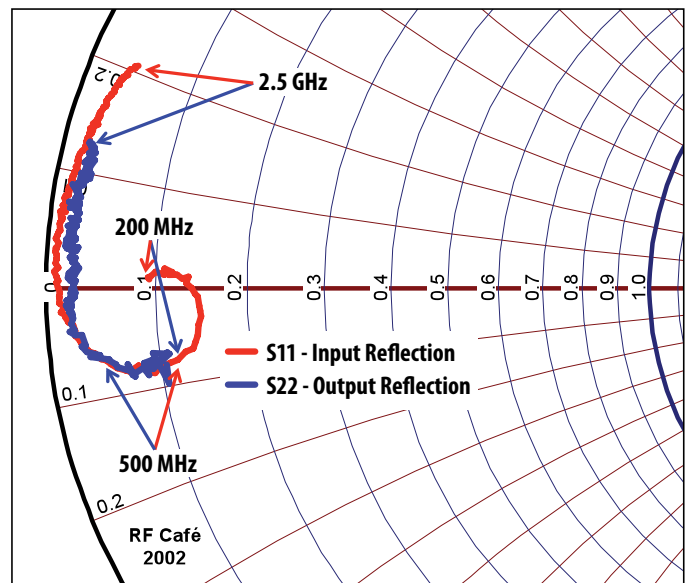


Figure 6: Smith Chart plot of Gate (S11) and Drain (S22) reflection for the EPC2012 over the frequency range 200 MHz through 2.5 GHz

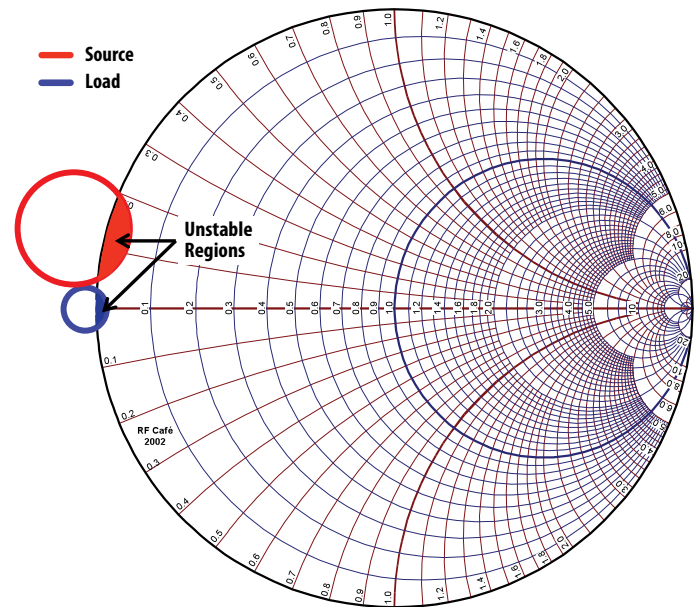


Figure 7: Stability Circle plot for the EPC2012 device at 500 MHz with 64 V, 1.275 A Drain bias

Since the real part of both the gate-source and drain-source impedances are smaller than the characteristic impedance of the transmission lines (50 Ω) used to connect the RF signal to the eGaN FET, the impedance matching network will take the form shown in Figure 8, where  $Z_L$  is the gate-source or drain-source impedance.

The basic matching network shown in Figure 8 has the following solutions [1]:

$$B = \pm \frac{1}{Z_0} \cdot \sqrt{\frac{Z_0 - R_L}{R_L}} \quad (1)$$

$$X = \pm \sqrt{R_L \cdot (Z_0 - R_L)} - X_L \quad (2)$$

Where  $Z_0$  is the characteristic impedance of the transmission line used to connect the RF signal to the eGaN FET.

A trombone section of the input microstrip transmission line can be used to tune the impedance matching network to the device at a specific frequency whereby a shunt matching component may be installed anywhere along its length. Using the calculated value for B (Figure 8), which in this case will be a capacitor, and moving it away from the FET on the 50 Ω transmission line, rotates the impedance clockwise on the Smith Chart with the result of shifting the impedance and altering the frequency response of the matching network. This is useful when designing an amplifier suitable for a wide operating frequency range.

### APPLICATIONS SUITABLE FOR THE EPC2012 EGAN FET

S-Parameter analysis of the EPC2012 eGaN FET has demonstrated that up to 635 MHz it has good gain (> 10 dB). This makes it useful for several applications, and in particular pulsed applications. These applications include Magnetic Resonance Imaging (MRI) Low power transmit systems and cyclotron drivers.

MRI systems operate in the frequency range from 42 MHz (1T systems) through 300 MHz (7T systems). During imaging, an RF pulse is transmitted into the subject. The EPC2012 has several electrical characteristics that make it suitable for use in MRI transmit systems. A magnetic susceptibility test was conducted by Case Western University to further determine if the EPC2012 was also suitable for use *inside* the MRI magnet. Any component inside the magnet must have an absolute volumetric magnetic susceptibility value of less than  $24 \cdot 10^{-6}$ . Figure 9 shows an MRI and photograph image from the magnetic susceptibility test and clearly shows that the EPC device has no impact on the image quality and is clearly distinguishable in the MRI image. A device which exceeds the magnetic susceptibility limits will distort the image and will clearly show up as either a large black spot or produce ripples on an image similar to a stone thrown in water.

Another application that is suitable for the EPC2012 device is a cyclotron driver. Such systems operate over a wide range of frequencies and are typically application specific. Cyclotrons are also pulsed and, due to the EPC2012's small size and high voltage rating, are ideally suited for these types of applications [2]. Future work may also explore applications such as WiFi, Bluetooth, Zigbee and M2M power amplifiers which all operate in pulse mode.

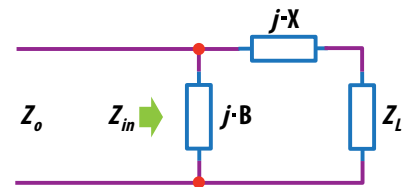


Figure 8: Suitable Matching network for the EPC2012 eGaN FET

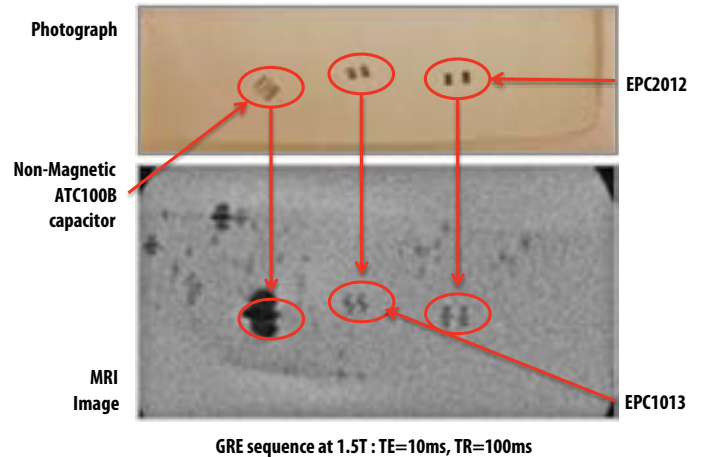


Figure 9: Image showing the magnetic susceptibility impact of the EPC2012 on a MRI image as compared to a non-magnetic ATC 100B series capacitor

For continuous wave (CW) applications the EPC2012 device would need to be in an appropriate RF package that is capable of dissipating large amounts of heat flux. Another option for the efficient removal of heat is eutectic die attach of the eGaN FET back side silicon directly to the circuit board substrate.

### CONCLUSIONS

Small signal S-parameter measurements of the EPC2012 show that the device exhibits good gain (> 10 dB) up to around 635 MHz. The EPC2012's small size limits its RF application thermally when used in class A or similar RF amplifiers. Applications requiring low on-time pulsed RF power are well suited to being driven by the EPC2012 eGaN FET where the total average power dissipation is kept below 5 W. Based on the experimental data, the basis for designing a class A RF amplifier was also given.

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